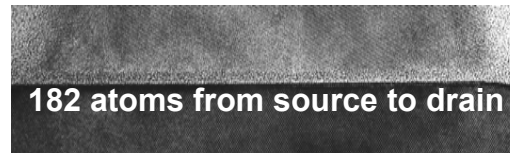
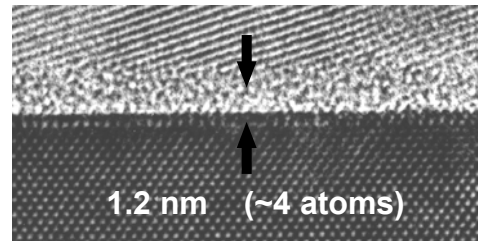
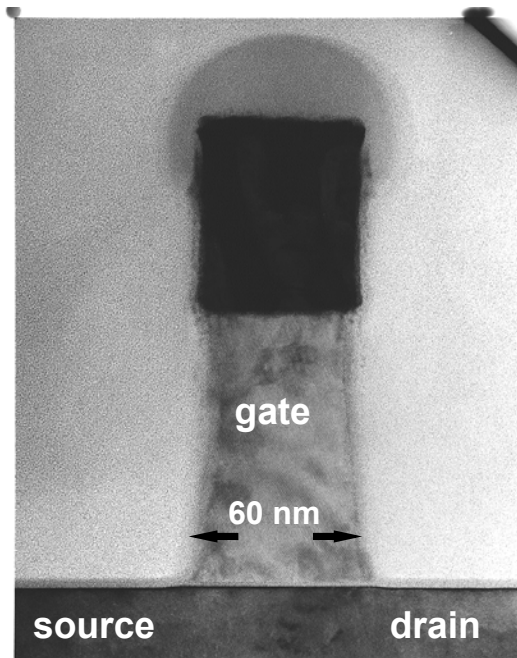


# **Marrying Reaction Chemistry to Surfaces**

**Colin Nuckolls**  
Department of Chemistry  
and  
The Nanoscience Center  
Columbia University

**NNI-Washington**  
**June 17, 2005**

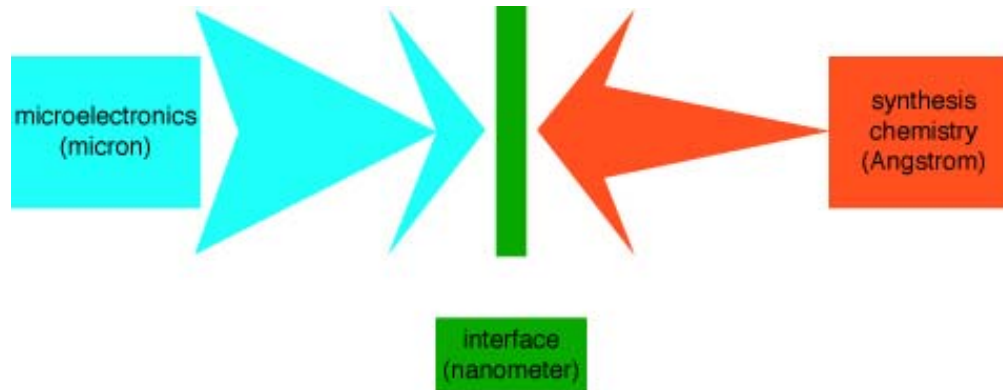
# Electronics: Smaller, faster, and cheaper



A real Field Effect Transistor

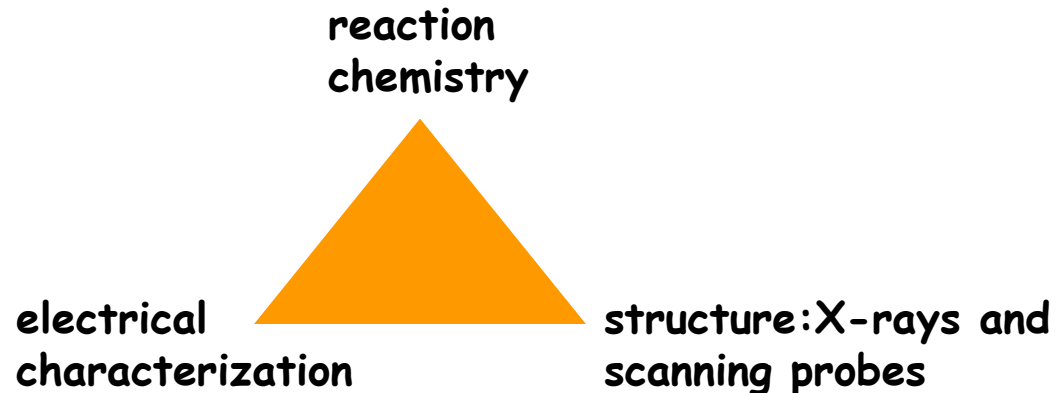
Next Generation of Devices will be a Network of Interfaces

# The Nexus of Fabrication and Synthesis is Interfaces

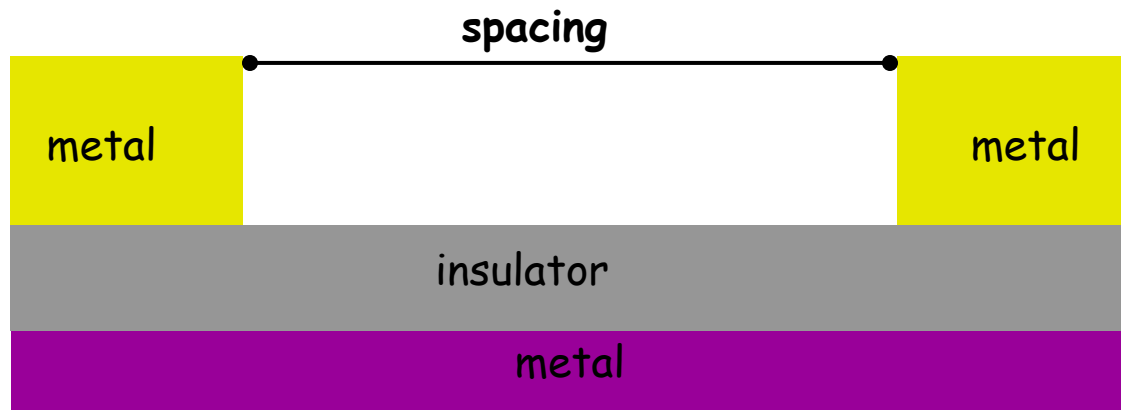


What does reaction chemistry bring to electronics?

- Self-assembly: programmed complexity
- Recognition
- Programmed reactivity (growth and in-plane):
- Functionality



# Integrating Reaction Chemistry with Devices



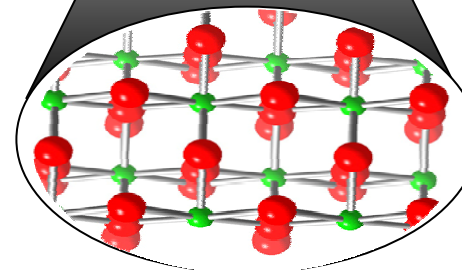
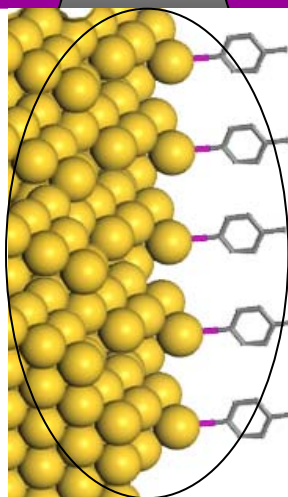
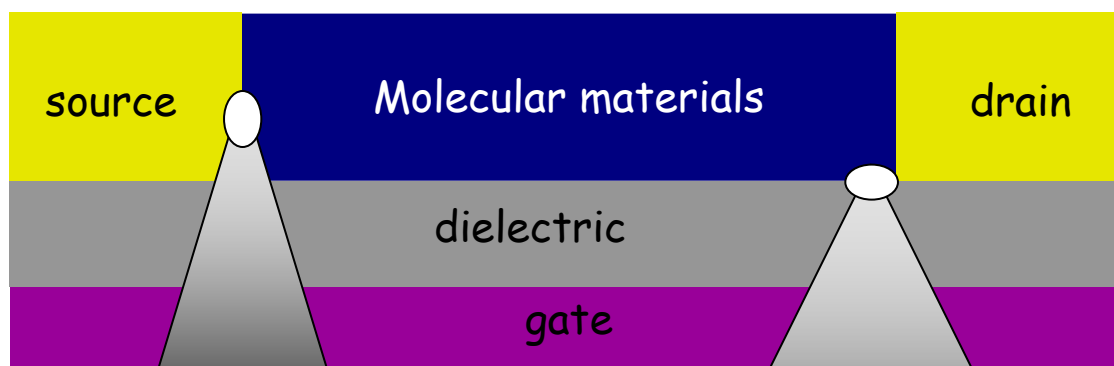
A diverse set of materials available: metals, semiconductors, and oxides

A range of sizes: atoms to centimeters

A sensitive reporter for assembly: *nothing* more sensitive

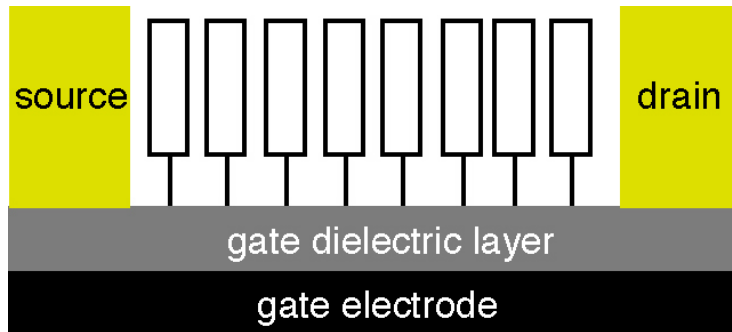
A sensitive reporter for chemical reactions

Technology: thin film, molecular, and hybrid devices



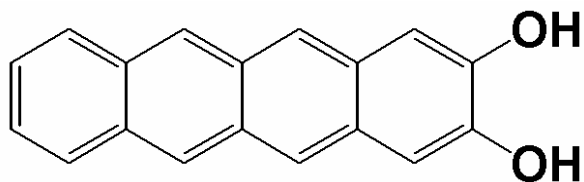
Can we synthesize  
this interface?

# Strategy



**Covalently Attached Monolayers**

# Self-Assembly on High K-Dielectrics



THF solution with  
 $\text{Al}_2\text{O}_3$  Surface

**Water Contact Angle:**

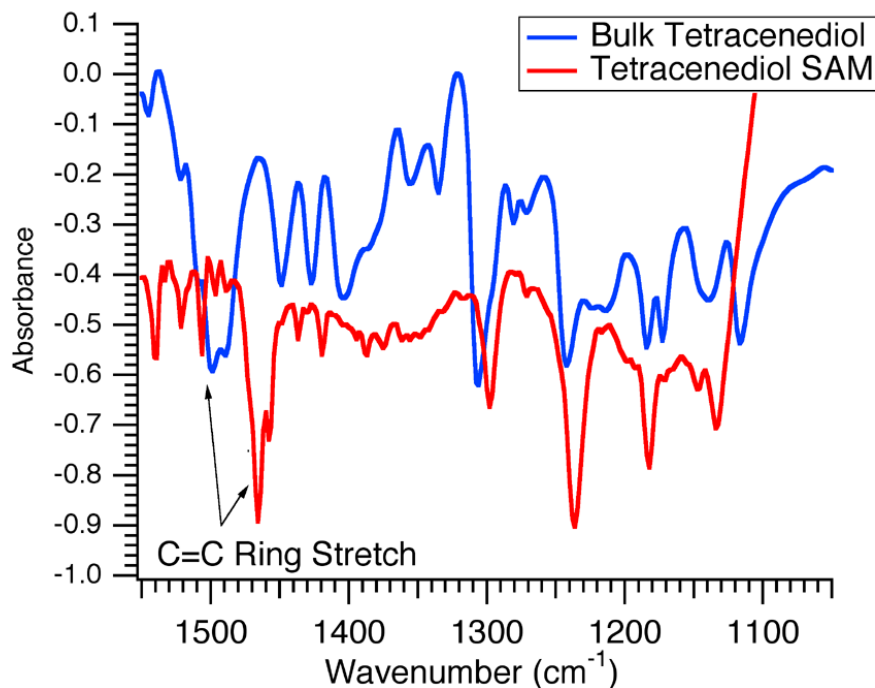
Advancing =  $76^\circ$

Receding =  $63^\circ$

## XPS

	$15^\circ$	$35^\circ$	$70^\circ$
O	31.4	36.4	41.2
C	47.1	36.3	26.2
Al	21.4	27.2	32.5
C/Al	2.20	1.34	0.81

## IRRAS Measurement



## Ellipsometry:

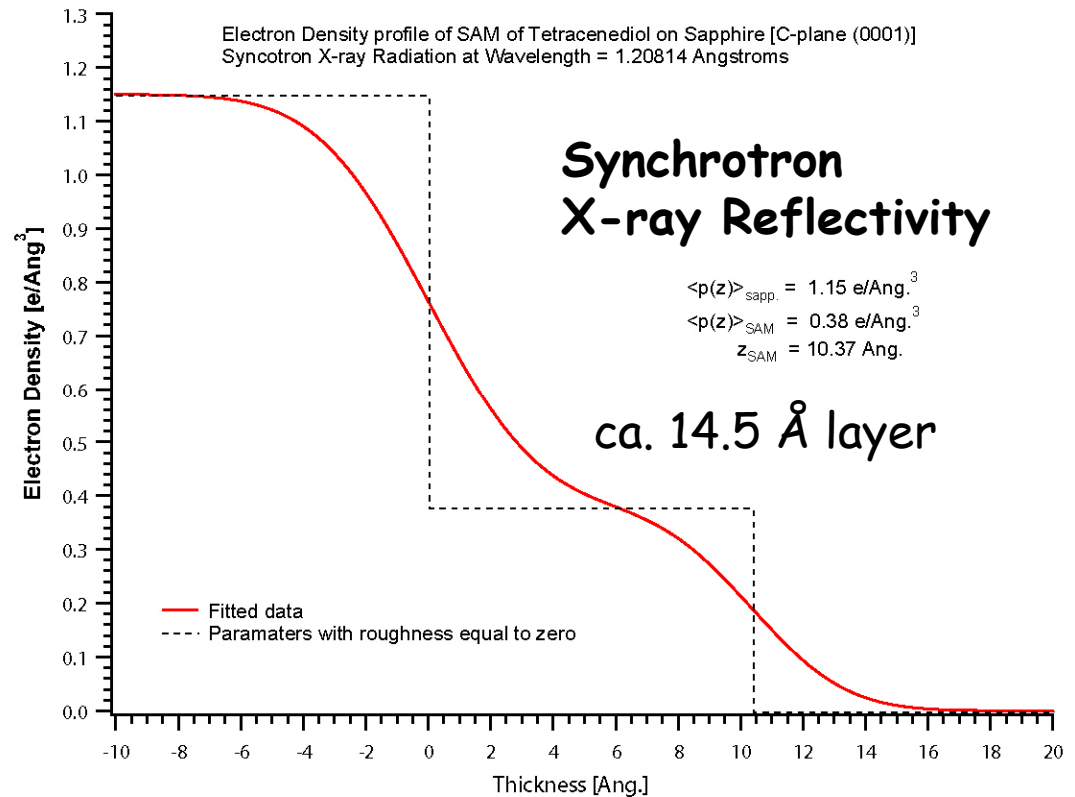
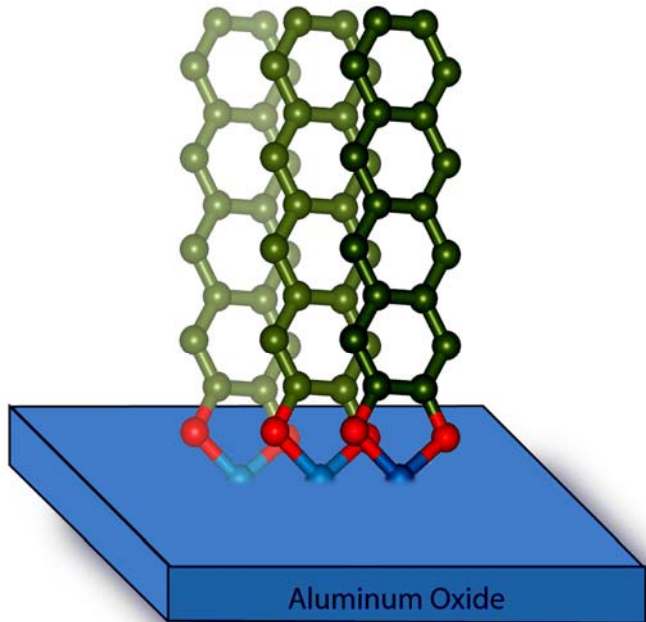
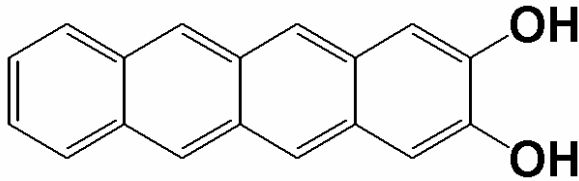
Measured Thickness =  $14.8 \text{ \AA}$

Calculated:  $14 \text{ \AA}$

Also:  $\text{HfO}_2$ ,  $\text{ZrO}_2$ , and  $\text{Y}_2\text{O}_3$

George Tulevski and Qian Miao

# Monolayers on sapphire crystals



electron density

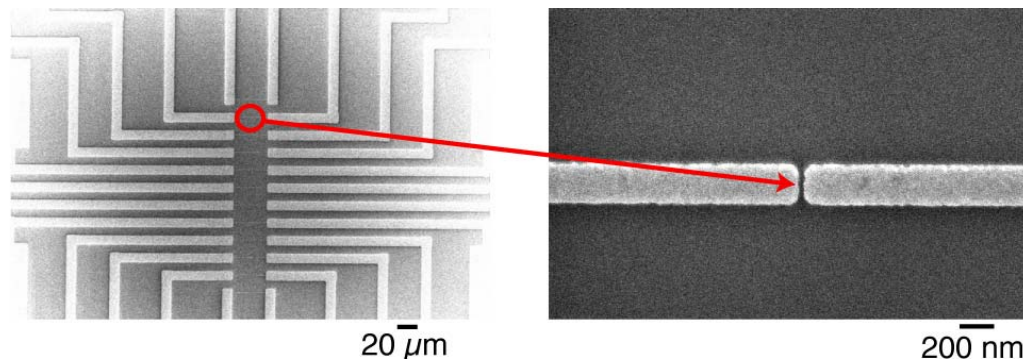
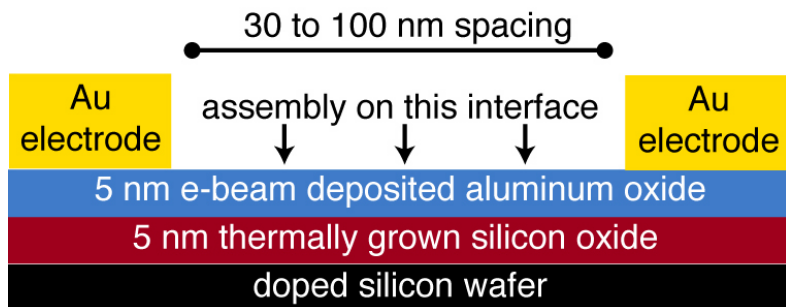
$0.38 \text{ e}/\text{\AA}^3$  for monolayer

$0.39 \text{ e}/\text{\AA}^3$  for tetracene crystal

**Columbia:** George Tulevski, Qian Miao, **BNL:** Masafumi Fukuto, Ben Ocko, Ron Pindak, **IBM:** Cherie Kagan

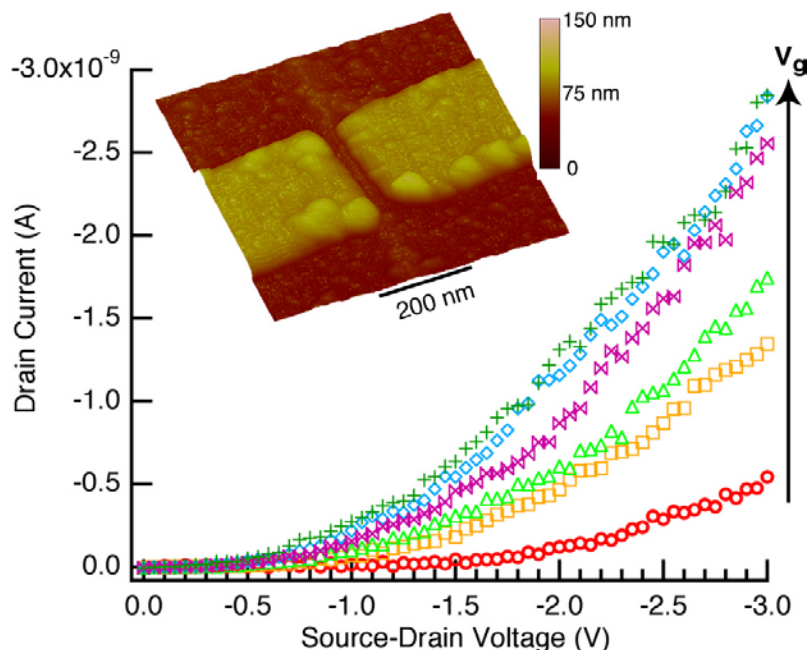


# Monolayer devices



500 sets on an 8" wafer

0.5 V steps



Yield: 42/80 devices  $\leq 60\ \text{nm}$  source-drain  
 Much lower  $> 60\ \text{nm}$   
 Grains of  $\text{Al}_2\text{O}_3$  are ca. 40 nm in diameter  
 Control experiments: catechol and naphthalene

40 nm device ~40,000 molecules

George Tulevski, Qian Miao, Cherie Kagan (IBM)

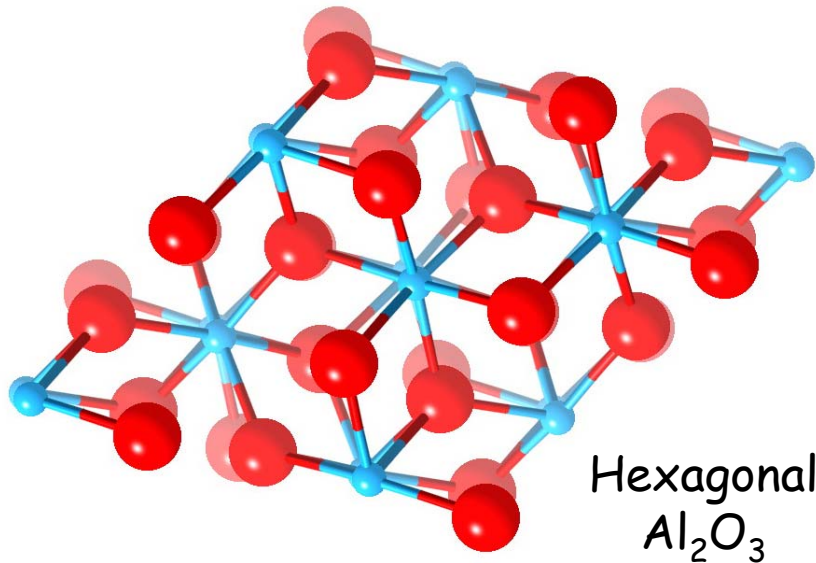
# The next step: tune the three interfaces



Source/Drain:  
Metal  
Derivatized

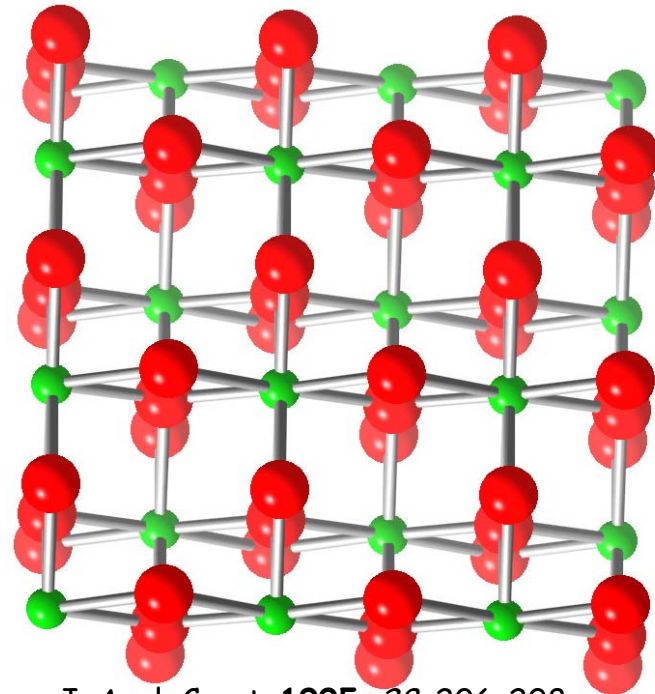
Gate dielectric:  
Aluminum oxide  
Hafnium oxide  
Zirconium oxide  
Crystalline

Viewing down the z-axis of  $\text{Al}_2\text{O}_3$  and  $\text{ZrO}_2$



Hexagonal  
 $\text{Al}_2\text{O}_3$

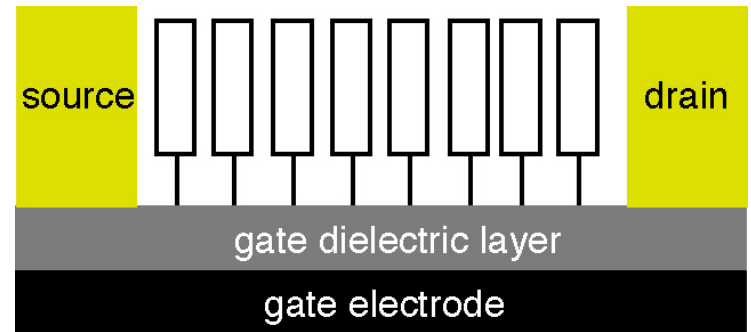
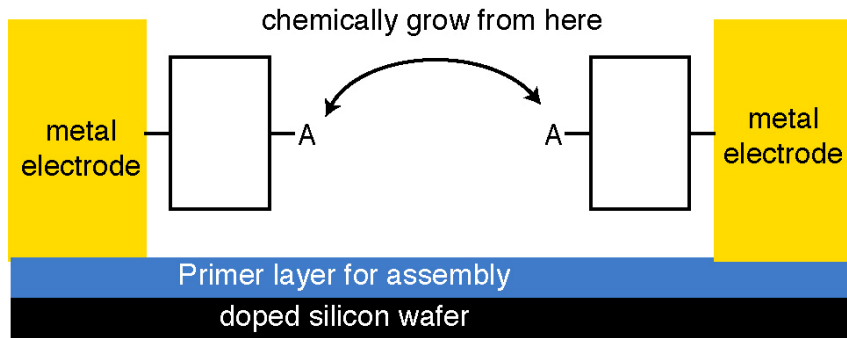
*J. Appl. Phys.* **1978**, *49*, 5823.



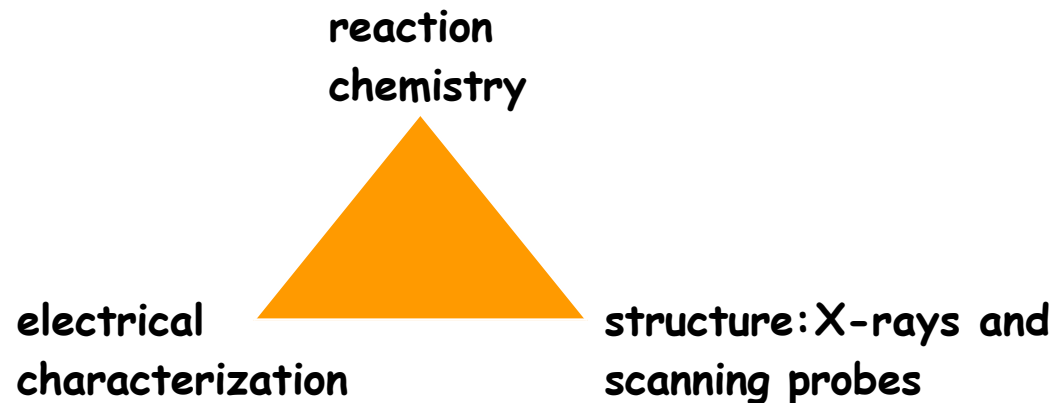
tetragonal  
 $\text{ZrO}_2$

*J. Appl. Cryst.* **1995**, *28*, 206-208

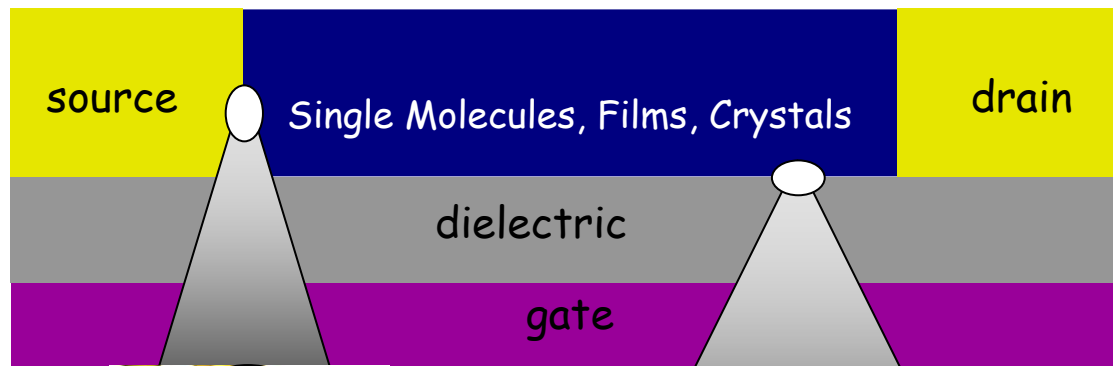
## Marry the two approaches



## In situ chemical reactions Synthesis of interfaces

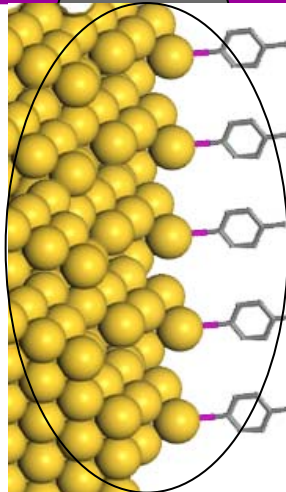


# Interfaces



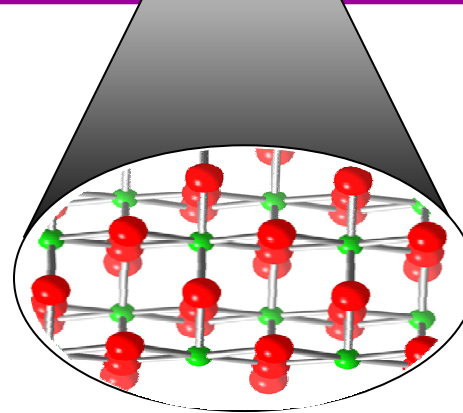
## Metal-Molecule Linkage

- CONTACT!
- Order
- Functionality:  
growth, recognition

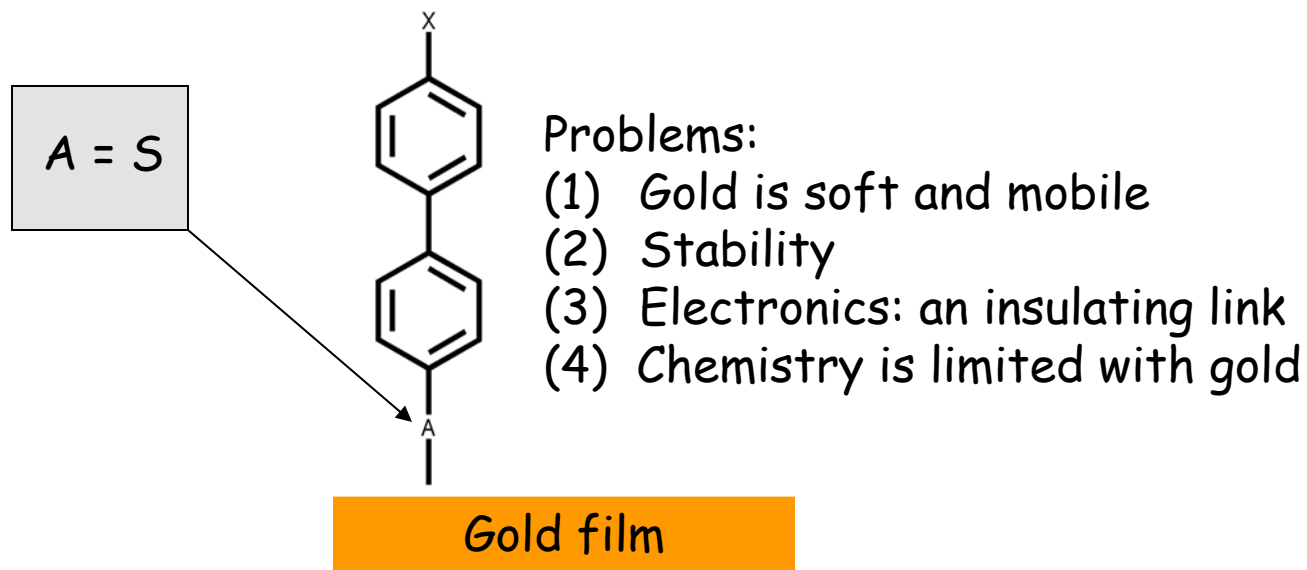


## Interfacial Assembly

- crystalline vs. glassy
- epitaxial growth
- multicomponent films



# Are there alternatives to thiol/gold?



What do we want?

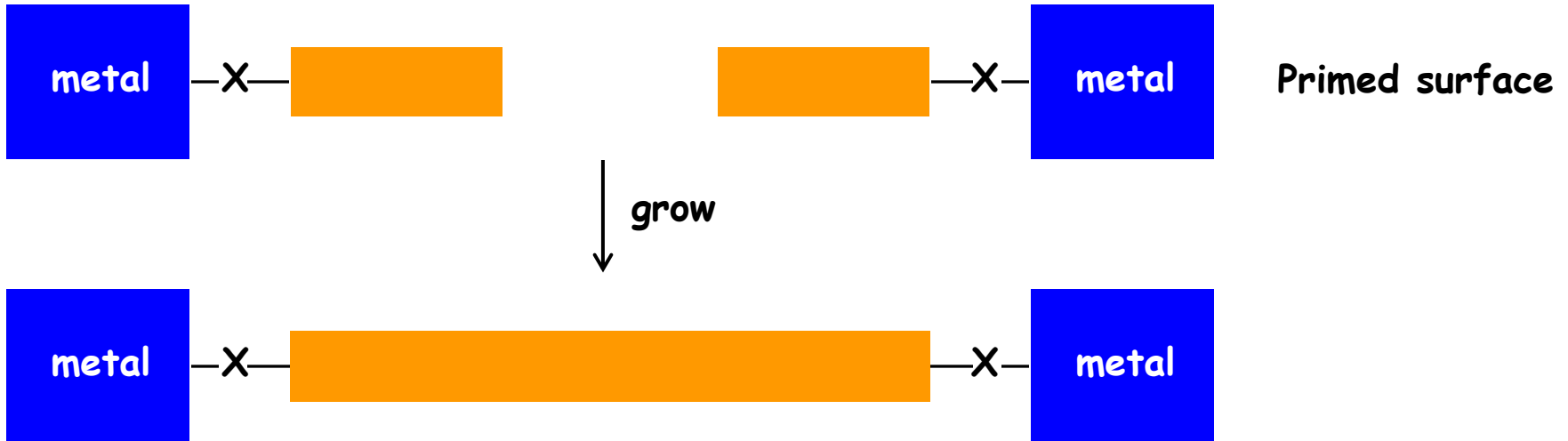
Strong

Chemically Stable

Transparent

Catalytic

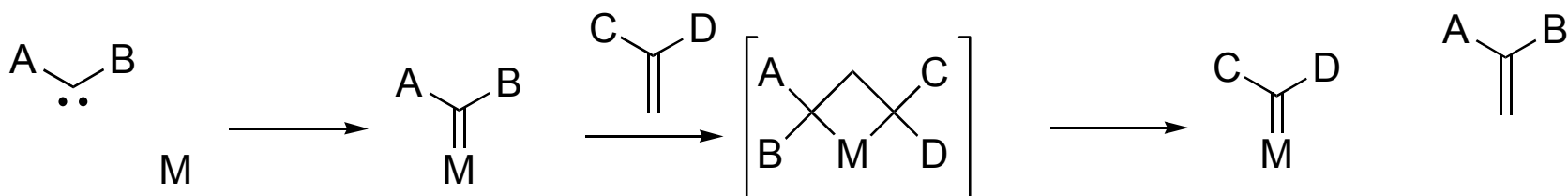
# We need to be able to vary the length Catalytic junctions--growth



What do we want?

Strong  
Chemically Stable  
Transparent  
Catalytic

# Metal-Carbon Multiple Bonds



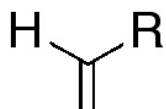
Questions:

Stability?

Which metals are best?

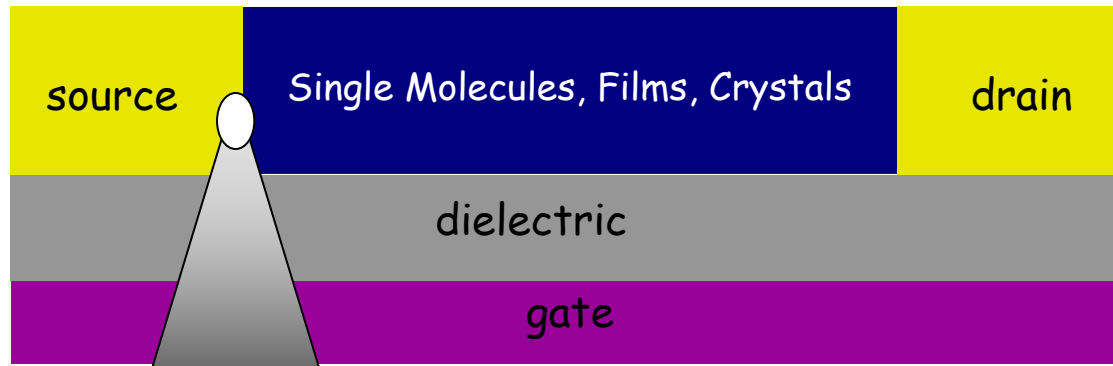
Which carbene substituents ?

What precursor?



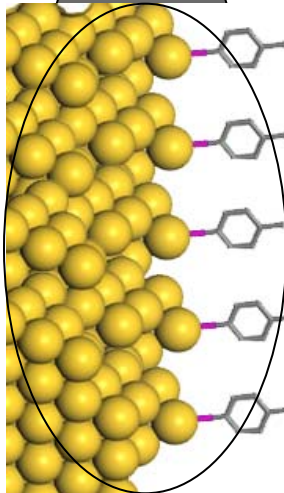
Metal film

# Tools that are needed in the toolkit



## Metal-Molecule Linkage

- CONTACT!
- Order
- Functionality:  
growth, recognition





**Need better tools to interrogate these!**

# Acknowledgements

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